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MS.

**AMENDMENTS TO THE CLAIMS**

1. (Canceled).
2. (Currently amended). The method of measuring a stability of a plating bath, according to claim ~~[[1]]~~ 15, wherein determining a concentration of said void-formation marker comprises:  
separating said void-formation marker from said plating bath liquor; and  
quantifying said void-formation marker.
3. (Original). The method of measuring a stability of a plating bath, according to claim 2, wherein said void-formation-marker is separated chromatographically.
4. (Original). The method of measuring a stability of a plating bath, according to claim 3, wherein said void-formation-marker is separated by liquid chromatography.
5. (Original). The method of measuring a stability of a plating bath, according to claim 3, wherein said void-formation-marker is separated by high performance liquid chromatography (HPLC).
6. (Original). The method of measuring a stability of a plating bath, according to claim 3, wherein said chromatography comprises ion-pairing, reversed-phase chromatography.
7. (Original). The method of measuring a stability of a plating bath, according to claim 2, wherein said quantifying is performed by instrumental analytical methods selected from the group consisting of spectroscopy and electrochemical detection.
8. (Original). The method of measuring a stability of a plating bath, according to claim 7, wherein said spectroscopy comprises techniques selected from the group consisting of ultraviolet, visible, infrared, and mass spectroscopy.